

Characterization of organic solar cells: Mechanical, electrical and photovoltaic stability

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Study of interfaces

Apply aging and study stability effect on interfaces by means of different methods:

- 1. Mechanical
- 2. Electrical
- 3. Optical



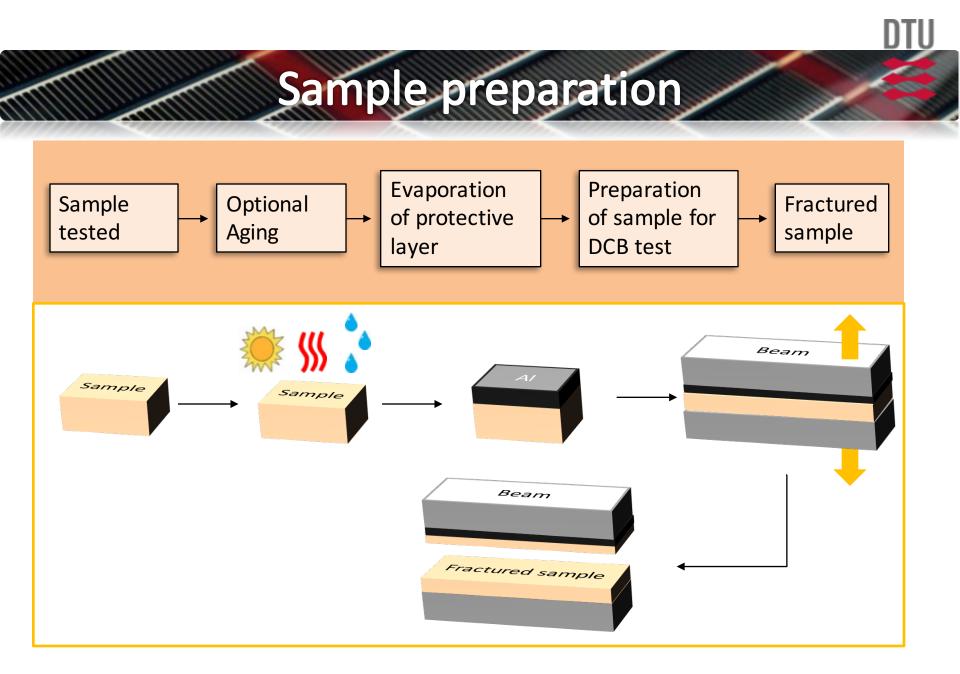
1.

Mechanical Methods

Mechanical techniques

- Double Cantilever Beam test
 - Measure the adhesion strenght of the weakest layer or interface within a structure
- Why?
 - Flexible devices are subjected to a lot of mechanical stress --> detect the weakest layer(s) and improve it
 - Understand influence of stress factors on the structure

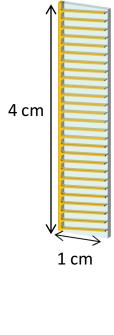






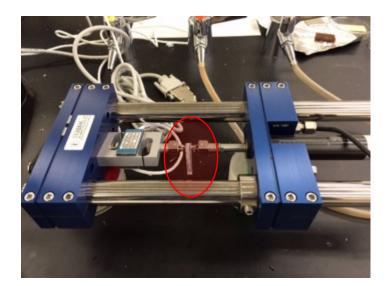
Double Cantilever Beam test

Flextrode (F)



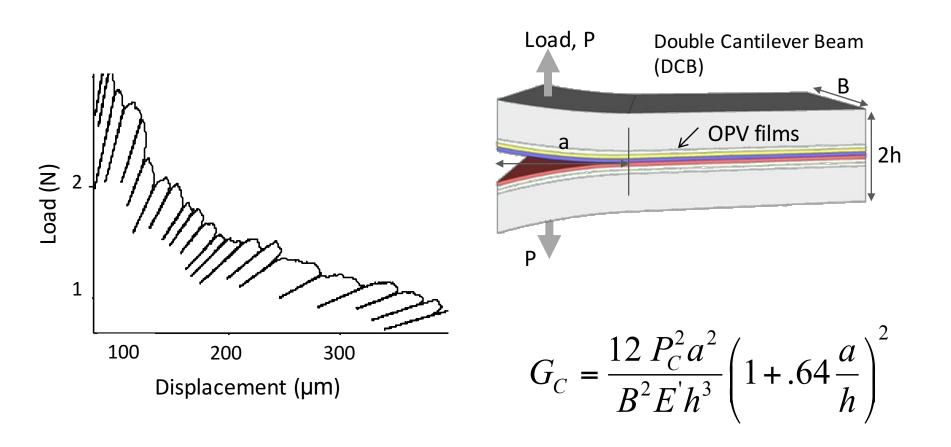






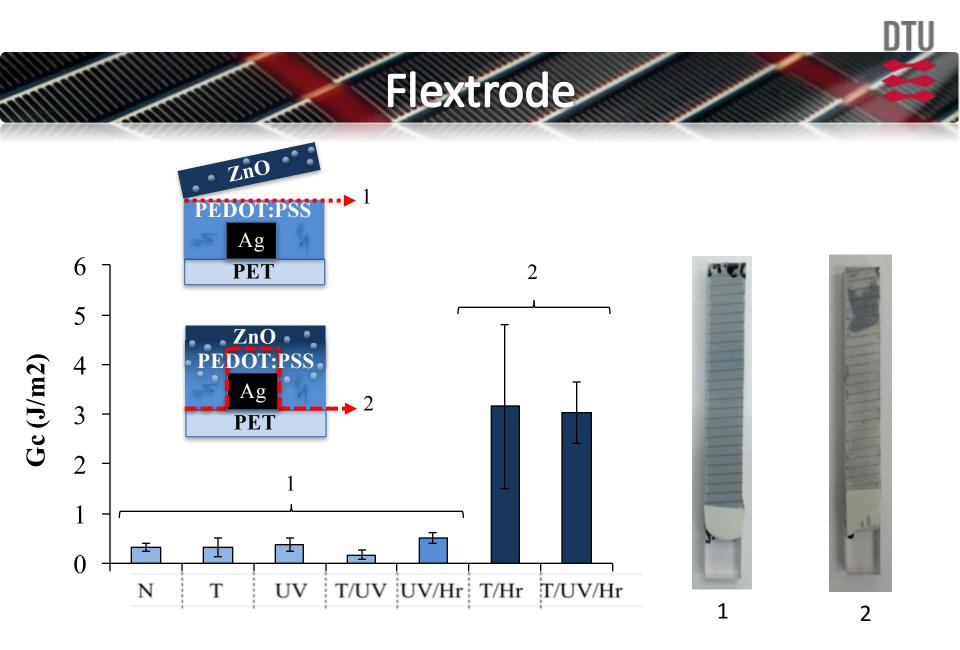


Load vs. Displacement



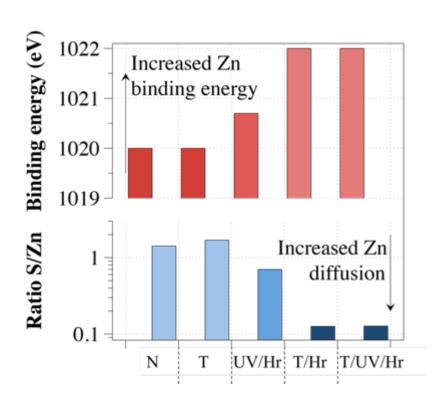
Aging conditions

	Т	T/Hr	UV	UV/Hr	T/UV	T/UV/Hr
Temperature (°C)	85	85	25	25	85	85
Humidity (% R.H.)	0	45	0	45	0	45
UV Irradiance (W/m ²)	0	0	30	30	30	30
Duration of ageing (h)	24	24	24	24	24	24

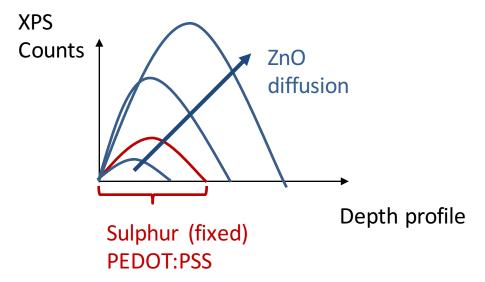




http://srdata.nist.gov/xps



Compound	Binding energy (eV)
ZnS	1022
Zn	1020-1021
ZnO	1020-1021





2.

Electrical Methods

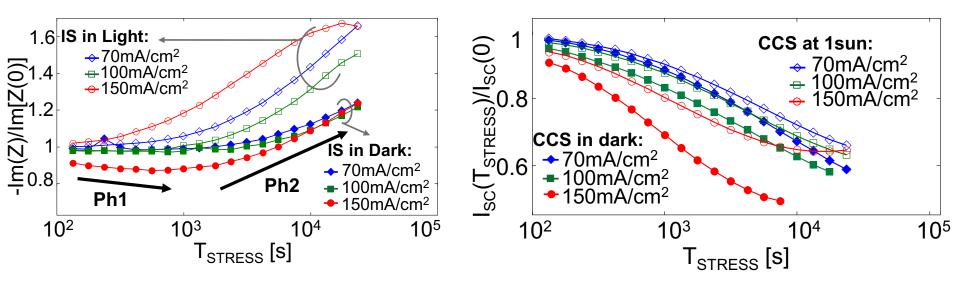
Electrical techniques

- Electrical methods:
 - IV curve characterization (PCE, FF, Isc, Voc)
 - Transient photocurrent/photovoltage (carrier dynamics and traps info)
 - Capacitance/Voltage (doping from built-in field and injection barriers)
 - Photo-CELIV (carriers mobility, recombination and doping density)

- Impedance spectroscopy:
 - complex ratio of the voltage to the current in an alternating current (AC) circuit, while variating the frequency.



Constant Current Stress: single cell



- Cells: P3HT:PCBM, 1 cm², inverted structure, encapsulated
- Only Recombination (dark) vs. Generation and Recombination (light)





IS under ISOS agings

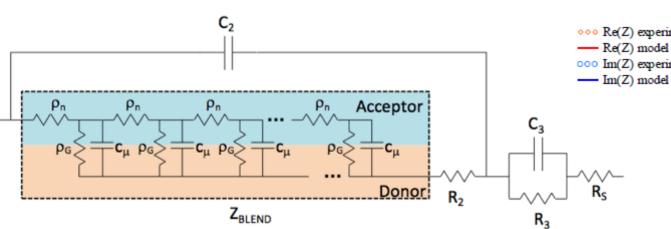
		ISOS-L2	ISOS-L3	ISOS-D3
Irradiance	[W/m ²]	1000	600	0
Temperature	[°C]	65	65	65
Humidity	[% R.H.]	low	50	85

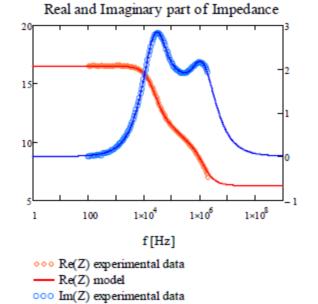


Modelling (IS)

Re(Z) [ohm]

- Measure of impedance in function of frequency
- Using a model, it is possible to gather information regarding the degradation at a specific interface





-Im(Z) [ohm]

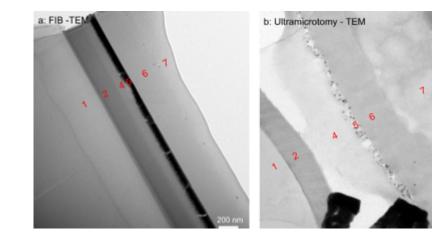


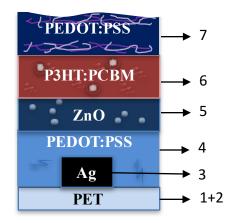
3. Optical Methods

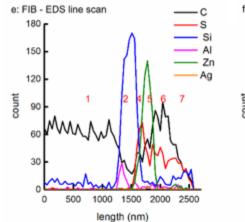
TEM and EDS

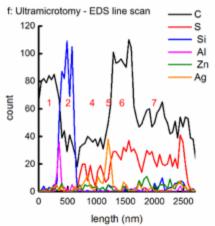
Transmission Electron Microscopy:

- High resolution imaging Preparation of samples:
- FIB
- Ultramicrotomy



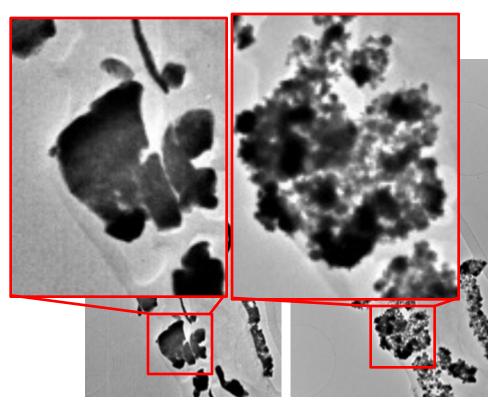


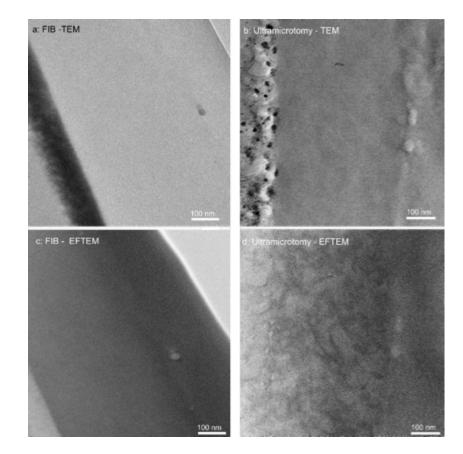




EFTEM + ISOS aging

- Using EFTEM for distinguishing P3HT:PCBM phase
- Aging study (ISOS-L-3)





Conclusions

- Several techniques are available for studying interfaces and device inner layers
- Combination of mechanical, electrical and imaging techniques offers the most complete vision to understand the effect of degradation
- Combination of appropriate stress factors and technique can allow to quickly address the effect of the aging factor on the stability of a device

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Thank you for your kind attention

